

**JPL ANALYTICAL CHEMISTRY LABORATORY**  
*Analytical Chemistry and Materials Development Group 3531*

T004

**To:** Robert Taylor, Helena Armandula **1/9/2008**  
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**Subject:** LIGO Molecular Contamination Analysis of OMC Structure and SEI Spring Posts

**Purpose**

Part surfaces were swab-sampled on site and submitted (1/8/08) for chemical analysis. This was to determine the level and identity of molecular (oily) contamination on the surface of parts.

**Method**

The analytical swabs consisted of extracted fiber-free lens tissue using Freon-TF solvent. The low volatility residue (LVR) was analyzed using Diffuse Reflectance/ Fourier Transform Infrared (DRIFT/FTIR) spectroscopy. FTIR provides chemical functional group information for quantitative analysis and qualitative identification of materials (1). The analysis followed the ACL-120 procedure that complies with IEST-STD-CC1246D and is sensitive to the most stringent level (A/100).

**Results and Discussion**

The samples have very low levels of oily residue removed (2). If the amount given below is divided by the area (no wipe areas were provided) the surface cleanliness level can be calculated. A level of 1 microgram per square centimeter ( $\mu\text{g}/\text{cm}^2$ ) corresponds to an average film thickness of 100 angstroms (assuming a density of 1.0).

Sample	Chemical Functional Group	Amount Total Micrograms $\mu\text{g}$
1. #1 Spring Post top&bottom 436.6 $\text{cm}^2$	AHC	1.2
2. #2 Spring Post 15taped holes	AHC	3.6
3. #3 Spring post 500 $\text{cm}^2$	Trace AHC	~0.5
4. D07107 Un tapped Holes 6	Trace AHC	~0.3
5. D07107-D004 Left side 200 $\text{cm}^2$	Trace AHC	~0.5
6. D07107-D 006 Right side 200 $\text{cm}^2$	Trace AHC	~0.5
7. D07107-D side with part number 400 $\text{cm}^2$	AHC	1.4
8. D07107-D 002 side without part number 400 $\text{cm}^2$	AHC	1.5
9. 1 OMC 12 holes	Trace AHC	0.6
10. OMC surface 100 $\text{cm}^2$	Trace AHC	~0.3

AHC: Aliphatic hydrocarbon, base oil of common lubricants

## References

1. M. S. Anderson et al "Analysis of Semi-Volatile Residues Using Diffuse Reflectance Infrared Fourier Transform Spectroscopy" in *Optical System Contamination: Effects, Measurements, and Control VII*; July 2002, edited by Phillip T. C. Chen and O. Manuel Lee; Proceedings of the SPIE, Vol. 4774, pp. 251-261, (2002).
2. The last mono-molecular layers are more complex to describe when cleaning or analyzing. Carbon/hydrocarbon based substances are known to rapidly (~1 hour) accumulate on most, if not all, freshly exposed surfaces. This "adventitious" carbon is well documented in clean rooms and vacuum systems and compositionally varies by environment. Adventitious carbon is a discontinuous layer of approximately ~0.2-1 nanometers thick or ~**0.02** to 0.1  $\mu\text{g}/\text{cm}^2$  (for  $\rho = 1$ ). The last mono-layer fractions may in some cases be strongly adsorbed to the surface as a "corrosion" layer. Therefore solvent based sampling methods may not remove these corrosion fractions. This is further complicated if the surface is porous. When specifying cleanliness level to less than level A/10 IEST-STD-CC1246D (0.1  $\mu\text{g}/\text{cm}^2$ ) these monolayer effects become more significant. See also: H. Piao and N. S. McIntyre, "Adventitious carbon growth on aluminum and gold-aluminum alloy surfaces", *Surf. Interface Anal.* 2002; 33: 591-594.
3. A typical solvent wipe has a detection limit of ~0.005  $\mu\text{g}/\text{cm}^2$  of removed residue from a 100 $\text{cm}^2$  sample. Note this limit is well below the adventitious carbon level. Lower limits are possible using modified methods. The wipe blanks are at levels less than 10% the amount removed from the sample and this is subtracted from the reported sample amount. High blanks (greater than 10%) are noted in the report.